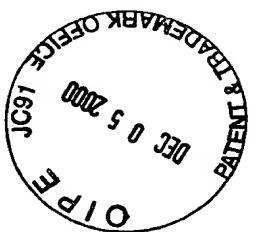


GP 2851
#21/G
12/00/00
XA-7889A Re

PATENT APPLICATION *GJR*



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Kenji NISHI

Appln. No.: 08/994,758

Group Art Unit: 2851

Filed: December 19, 1997

Examiner: A. Mathews

For: PROJECTION EXPOSURE APPARATUS

* * *

SUPPLEMENTAL AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

RECEIVED
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Sir:

Supplementing the Amendment filed October 6, 2000,
please further amend the above-identified as indicated
below.

IN THE CLAIMS:

- 1 35. (Amended) A scanning exposure apparatus for
2 projecting a pattern image of a mask onto a sensitive plate
3 through a projection system having a predetermined
4 magnification ratio in a scanning manner, the apparatus
5 comprising:
6 (a) a scanning system which has a first driving system
7 to move the mask and a second driving system to move the
8 plate and which synchronously scans the mask and the plate

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